V .	Application No.	Applicant(s)
Notice of Allowability	10/602,462	BEDELL ET AL.
	Examiner	Art Unit
	Tianjie Chen	2627
The MAILING DATE of this communication appeal All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in or other appropriate comm IGHTS. This application is	n this application. If not included unication will be mailed in due course. THIS
1. This communication is responsive to <u>telephone interview of</u>	conducted on 02/12/2008.	
2. The allowed claim(s) is/are <u>25-50</u> .		
<ul> <li>3.  Acknowledgment is made of a claim for foreign priority una)  All b)  Some* c)  None of the:</li> <li>1.  Certified copies of the priority documents have</li> <li>2.  Certified copies of the priority documents have</li> <li>3.  Copies of the certified copies of the priority do</li> </ul>	e been received. e been received in Application	on No
International Bureau (PCT Rule 17.2(a)).  * Certified copies not received:	,	
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.  4. A SUBSTITUTE OATH OR DECLARATION must be subm	MENT of this application.	
INFORMAL PATENT APPLICATION (PTO-152) which give		
5. CORRECTED DRAWINGS ( as "replacement sheets") must		
(a) ☐ including changes required by the Notice of Draftspers		w ( PTO-948) attached
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date		
(b) including changes required by the attached Examiner' Paper No./Mail Date	•	
Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in t	:.84(c)) should be written on t the header according to 37 Cl	re drawings in the front (not the back) of FR 1.121(d).
<ol> <li>DEPOSIT OF and/or INFORMATION about the depo attached Examiner's comment regarding REQUIREMENT</li> </ol>	SIT OF BIOLOGICAL MAT FOR THE DEPOSIT OF BI	ERIAL must be submitted. Note the OLOGICAL MATERIAL.
Attachment(s) 1. ☐ Notice of References Cited (PTO-892)	5. ☐ Notice of Ir	nformal Patent Application
2.  Notice of Draftperson's Patent Drawing Review (PTO-948)		ummary (PTO-413),
3. Information Disclosure Statements (PTO/SB/08), Paper No./Mail Date		/Mail Date <u>02/12/2008</u> . Amendment/Comment
4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	8. 🛭 Examiner's	Statement of Reasons for Allowance
	9.	Chen Transpo
		TIANJIE CHEN PRIMARY EXAMINER

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## **EXAMINER'S AMENDMENT**

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Dominic M. Kotab on 2/12/2008.

The application has been amended as follows:

- In claim 25, line 4; "a channel" has been changed to --a channel with a plurality of turns--.
- In claim 25, line 6; "the channel" as been changed to --the channel with a plurality of turns--.
- In claim 36, line 4; "a channel" has been changed to --a channel with a plurality of turns--.
- In claim 36, line 6; "the channel" as been changed to --the channel with a plurality of turns--.
- In claim 37, line 6; "at least one channel" has been changed to --at least one channel with a plurality of turns--.
- In claim 37, line 7; "the channel" has been changed to --the channel with a plurality of turns--.
- In claim 38, lines 3-4; "at least a channel" has been changed to --at least a channel with a plurality of turns--.

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• In claim 38, lines 5-6; "the at least one channel" has been changed to --the at least one channel with a plurality of turns--.

## Reasons for Allowance

- 2. The following is an examiner's statement of reasons for allowance:
  - With regard to independent claims 25, 36, and 37; as the closest reference of record, Sato (US 6,757,133) discloses magnetic head, comprising: an underlying layer, the underlying layer being electrically insulating; a photoresist layer positioned adjacent the underlying layer and having two opposing sides defining a channel with a plurality of turns, a bottom of the channel extending between the opposing sides being defined by the underlying layer; and a coil structure formed of a conductive material situated in the channel with a plurality of turns; but fails to show that a profile of each of the sides of the photoresist layer that define the channel includes a first segment and a second segment that is contiguous with the first segment, the first segment defining a first angle relative to a plane of deposition of the photoresist layer, the second segment defining a second angle relative to the plane of deposition of the photoresist layer, the second angle being different than the first angle, wherein the first segment of each side of the photoresist layer is positioned below the second segment located contiguously thereto, wherein a height of thee first segment of each side of the photoresist layer measured perpendicular to the plane of deposition of

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the photoresist layer extends from the underlying layer to a point between 20% and 80% of a total channel height from a top of the channel.

- With regard to independent claim 38; as the closest reference of record, Sato (US 6,757,133) discloses a magnetic head, comprising: an insulating layer; a photoresist layer positioned adjacent the insulating layer for defining at least one channel with a plurality of turns; and a coil structure defined by a conductive material situated in the at least one channel; but fails to show that the photoresist layer does not overlay the coil structure; wherein a profile of the channel includes a first segment defining a first angle relative to a plane of deposition of the photoresist layer, and a second segment continuous with the first segment, the second segment defining a second angle relative to a plane of deposition of the photoresist layer, the second angle being different than the first angle.
- Applicant declares; "The present invention relates to magnetic head coil
  Structures, and more particularly, this invention relates to improving the
  fabrication of high aspect ratio and narrow coil pitch magnetic head coil
  structures" (Specification, p. 1).

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Tianjie Chen whose telephone number is 571-272-

7570. The examiner can normally be reached on 8:00-4:30, Mon-Fri.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Hoa Nguyen can be reached on 571-272-7579. The fax phone number for

the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the

Patent Application Information Retrieval (PAIR) system. Status information for

published applications may be obtained from either Private PAIR or Public PAIR.

Status information for unpublished applications is available through Private PAIR

only. For more information about the PAIR system, see http://pair-direct.uspto.gov.

Should you have questions on access to the Private PAIR system, contact the

Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like

assistance from a USPTO Customer Service Representative or access to the automated

information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

TIANJIE CHEN

PRIMARY EXAMINER